

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	308	(SOG or "silicon on glass" or SiOC) and (C4F8 or "C.sub.4F.sub.8" or C4F6 or "C.sub.4F.sub.6") and (oxygen or "O.sub.2")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:08
L2	9607	"dual damascene"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:09
L3	446	(SOG or "silicon on glass" or "low k") and (C4F8 or "C.sub.4F.sub.8" or C4F6 or "C.sub.4F.sub.6" or fluocarbon) and (oxygen or "O.sub.2") and (trench or via)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:10
L4	1196	(dielectric or insulating or "low k") and (C4F8 or "C.sub.4F.sub.8" or C4F6 or "C.sub.4F.sub.6" or fluocarbon) and (oxygen or "O.sub.2") and (trench or via)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:11
L5	330	4 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:11
L6	115	(dielectric or insulating or "low k") same (C4F8 or "C.sub.4F.sub.8" or C4F6 or "C.sub.4F.sub.6" or fluocarbon) same (oxygen or "O.sub.2") same (trench or via)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:12
L7	340	(dielectric or insulating or "low k") and (C4F8 or "C.sub.4F.sub.8" or C4F6 or "C.sub.4F.sub.6" or fluocarbon) and (oxygen or "O.sub.2") and (interconnect or metaliz\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/05/11 15:13